

Mask Marking Scheme

Expectations / Criteria	Level 1 (0-5 marks)	Level 2 (6 marks)	Level 3 (7 marks)	Level 4 (8-10 marks)
<p>FOUNDATIONS</p> <p><i>Planning, proposal, sketches, use of time, preparedness</i></p>	Lacks effort to effectively plan out design, sketches lack clarity, poor use of time, not prepared	Somewhat planned, proposal and sketches are mostly clear, inconsistent use of time and preparedness	Good plan, proposal complete, sketches are clear, good use of time, mostly prepared	Excellent plan, proposal and sketches, excellent use of time, consistently prepared
<p>CREATION</p> <p><i>Following the steps in the creative process</i></p> <p><i>Mask is accurate to proposed design, shows understanding of good technique, creative</i></p> <p><i>Quality of finished product and polished look</i></p>	<p>Does not follow</p> <p>Does not</p> <p>Lacks quality</p>	<p>Sometimes follows</p> <p>Sometimes</p> <p>Somewhat polished look with some quality</p>	<p>Mostly follows</p> <p>Most if the time</p> <p>Good quality and polished</p>	<p>Always</p> <p>Always</p> <p>Excellent quality and very polished</p>
<p>REFLECTION</p> <p><i>Formal Critique handout</i></p>	Incomplete	Complete but lacks clarity, effort, thoughtfulness	Complete, clear, effort evident, thoughtful	Complete, clear, effort evident, very thoughtful and thought-provoking, well-written

Foundations: /10

Creation: /30

Reflection: /10

Total: /50

%